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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/560,268	04/26/2000	Whonchee Lee	150.0056 0102	2517
7590 03/09/2004			EXAMINER	
Attn Mark J Gebhardt			DEO, DUY V	U NGUYEN
Mueting Raasch Gebhardt PA PO Box 581415			ART UNIT	PAPER NUMBER
Minneapolis, MN 55458-1415			1765	

DATE MAILED: 03/09/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

•	Application No.	Applicant(s)			
	09/560,268	LEE ET AL.			
Office Action Summary	Examiner	Art Unit			
	DuyVu n Deo	1765			
The MAILING DATE of this communic	cation appears on the cover sheet v	with the correspondence address			
A SHORTENED STATUTORY PERIOD FOTHE MAILING DATE OF THIS COMMUNION. - Extensions of time may be available under the provisions of after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30). - If NO period for reply is specified above, the maximum statent of the period for reply within the set or extended period for reply wany reply received by the Office later than three months after earned patent term adjustment. See 37 CFR 1.704(b).	CATION. of 37 CFR 1.136(a). In no event, however, may a unication. days, a reply within the statutory minimum of the cutory period will apply and will expire SIX (6) MC will, by statute, cause the application to become	a reply be timely filed nirty (30) days will be considered timely. DNTHS from the mailing date of this communication. ABANDONED (35 U.S.C. § 133).			
Status					
1)⊠ Responsive to communication(s) filed	d on 22√a⊕uarv 2004				
	b) This action is non-final.				
<u></u>	3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is				
closed in accordance with the practic	· · · · · · · · · · · · · · · · · · ·	•			
Disposition of Claims					
4) Claim(s) 64,65,67-76,89,90 and 92-9	5 is/are pending in the application	ı.			
4a) Of the above claim(s) is/arc					
5) Claim(s) <u>68-76,89, 90, 92, 93</u> is/are	allowed.				
6) Claim(s) 64,65,67,94 and 95 is/are re					
7) Claim(s) is/are objected to.					
8) Claim(s) are subject to restrict	ion and/or election requirement.				
Application Papers					
9)☐ The specification is objected to by the	Examiner.				
10) The drawing(s) filed on is/are:		b by the Examiner.			
Applicant may not request that any object					
Replacement drawing sheet(s) including t	=- ,	, ·			
11) The oath or declaration is objected to	,	-			
Priority under 35 U.S.C. § 119					
12)☐ Acknowledgment is made of a claim for a)☐ All b)☐ Some * c)☐ None of:	or foreign priority under 35 U.S.C.	§ 119(a)-(d) or (f).			
1. Certified copies of the priority d	locuments have been received.				
	locuments have been received in	Application No			
<u> </u>	f the priority documents have bee	· · · · · · · · · · · · · · · · · · ·			
application from the Internation	•	· ·			
* See the attached detailed Office action	, , , , , , , , , , , , , , , , , , , ,	ot received.			
Attachment(s)					
1) Notice of References Cited (PTO-892)	4) Interview	Summary (PTO-413)			
2) 🔲 Notice of Draftsperson's Patent Drawing Review (PT	O-948) Paper No	o(s)/Mail Date			
 Information Disclosure Statement(s) (PTO-1449 or P Paper No(s)/Mail Date 	PTO/SB/08) 5) ☐ Notice of 6) ☐ Other:	Informal Patent Application (PTO-152)			
5. Patent and Trademark Office TOL-326 (Rev. 1-04)	Office Action Summary	Part of Paper No./Mail Date 030404			

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DETAILED ACTION

Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 64, 65, 67, 94, 95 are rejected under 35 U.S.C. 103(a) as being unpatentable over Nakano (US 6,110,839), Shiramizu (US 6,116,254), and Wei (US 4,350,564).

Nakano teaches a solution (claimed etching composition) comprising: HCl (claimed mineral acid), H2O2 (claimed peroxide), and water with their respective ratio of 1:1:10 (col. 6, line 39-44). Unlike claimed invention, Nakano is silent about using DI water; however, using DI or pure water to prepare similar chemical bath is well known to one skilled in the art as shown by Shiramizu (col. 1, line 32), and would have been obvious so that the chemical bath doesn't contain other contamination.

Unlike claimed invention, Nakano doesn't describe the HCl:H2O2:water concentration is at 1:1:25-1:1:15 respectively. However, chemical concentration is a result-effective variable as shown here by Wei (col. 4, line 34, 35). Therefore, it would have been obvious for one skill in the art to determine the chemical composition through test run in order to obtain optimum chemical concentration to provide a solution to remove metal impurities with a reasonable expectation of success. See also *In re Boesch*, 617, F.2d 272, 205 USPQ 215 (CCPA 1980).

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Referring to claim 94, unlike claimed invention, Nakano doesn't describe HCl and H2O2 being used have a concentration of 37 wt% and 29 wt% respectively. However, he teaches HCl and H2O2 having concentration of 36 wt% and 30 wt% respectively. These concentration would essentially is the same as claimed concentration. It would have been obvious at the time of the invention for one skilled in the art that the final concentration being used would depend on the desired etch rate and material being etched; therefore, one skilled in the art would determine the chemical concentration through test run in order to obtain the optimum chemical concentration for the etching with a reasonable expectation of success. See also *In re Boesch*, 617, F.2d 272, 205 USPQ 215 (CCPA 1980).

Response to Arguments

- 3. Applicant's arguments, see the remarks, filed 1/22/04, with respect to claims 68-76, 89, 90, 92, and 93 have been fully considered and are persuasive. The rejection of these claims has been withdrawn. Applicant's argument that Nakano describes similar components in the solution but doesn't suggest or lead on skill in the art to modify the solution such that a specific etch rates for either cobalt and/or metal nitride at specific temperature is found persuasive.
- 4. Applicant's arguments to the rejection of claims 64, 65, 67, 94, 95 have been fully considered but they are not persuasive. The merely argument that determining the optimum ratio through routine experimentation is not appropriate in this case is found unpersuasive.

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The motivation for doing the test runs, which any skill in the art would have to always perform before any actual process is carrying out, is to obtain optimum processing parameters including ratio, T for the remove the metal impurities.

In response to applicant's argument that the examiner's conclusion of obviousness is based upon improper hindsight reasoning, it must be recognized that any judgment on obviousness is in a sense necessarily a reconstruction based upon hindsight reasoning. But so long as it takes into account only knowledge which was within the level of ordinary skill at the time the claimed invention was made, and does not include knowledge gleaned only from the applicant's disclosure, such a reconstruction is proper. See *In re McLaughlin*, 443 F.2d 1392, 170 USPQ 209 (CCPA 1971).

In response to applicant's argument that the references fail to show certain features of applicant's invention, it is noted that the features upon which applicant relies (i.e. the solution capable of etching particular materials such as cobalt and metal nitride at particular advantageous rates or modifying the cleaning solution would become less reactive as opposed o having etching characteristics of etching cobalt and/or metal nitride,) are not recited in the rejected claim(s). Although the claims are interpreted in light of the specification, limitations from the specification are not read into the claims. See *In re Van Geuns*, 988 F.2d 1181, 26 USPQ2d 1057 (Fed. Cir. 1993). Claims 64, 65, 67, 94, 95 do not claim etching any particular materials at any particular rates. They only claim a composition of compounds at certain ratio.

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Allowable Subject Matter

5. Claims 68-76, 89, 90, 92, and 93 allowed because applicant's argument that Nakano describes similar components in the solution but doesn't suggest or lead on skill in the art to modify the solution such that a specific etch rates for either cobalt (greater than 1000 angstrom/min) and/or metal nitride (50-250 angstrom/min) at specific temperature (20-100 degrees Celsius) is found persuasive.

Conclusion

6. THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

7. Any inquiry concerning this communication or earlier communications from the examiner should be directed to DuyVu n Deo whose telephone number is 703-305-0515.

7: "

DVD 10/14/03

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